

2025년 2월 12일(수)-14일(금) | 강원도 하이원리조트

Future Normal in Semiconductor

2025-02-13(목), 09:00-10:45 좌장: 추후업데이트 예정

D. Thin Film Process Technology 분과 [TE1-D] Ferroelectrics

TE1-D-1	BEOL-compatible and Robust Ferroelectricity in 5 nm-thick $Hf_{0.5}Zr_{0.5}O_2$					
	film by Adopting TiN and Mo Alloy Electrode					
09:00-09:15	Jaewook Lee, Yong Hyeon Cho, Hyeong Seok Choi, Hyun Woo Jeong, Hyojun Choi,					
09.00-09.15	and Min Hyuk Park					
	Seoul National University					
	N-Terminated TiN Electrodes with (111) Texture for Low-Voltage					
TE1-D-2	Switching (0.8 V) in Ferroelectric $Hf_{0.5}Zr_{0.5}O_2$ Capacitors					
09:15-09:30	Geun Hyeong Park ¹ , Yong Hyeon Cho ¹ , Dong Hyun Lee ¹ , Se Hyun Kim ¹ , Ho Jun Kim ² ,					
09.15-09.30	and Min Hyuk Park ¹					
	¹ Seoul National University, ² Hanyang University					
	BEOL-Compatible Fabrication of Reliable FeFETs with Sub 10nm Hf_xZr_1					
TE1-D-3 09:30-09:45	-xO2 Films					
	Geonwook Kim ¹ , Hyunho Seok ² , Sihoon Son ² , Hyunbin Choi ³ , Jinhyoung Lee ¹ , and					
	Taesung Kim ^{1,2,3}					
	¹ Department of Mechanical Engineering, Sungkyunkwan University, ² SKKU Advance					
	Institute of Nano Technology, ³ Department of Semiconductor Convergence					
	Engineering, Sungkyunkwan University					
	Enhancing Memory Characteristics of MIFIS-FeFET: Effects of Si_3N_4					
	Charge Injection Layer and Its Composition					
TE1-D-4	Hyojin Ahn ¹ , Hyunjin Lim ¹ , Sangkuk Han ¹ , Yehbeen Im ¹ , Wonjae Choi ² , Youngseo					
09:45-10:00	Na ² , and Changhwan Choi ^{1,2}					
	¹ Division of Materials Science and Engineering, Hanyang University, ² Department of					
	Semiconductor Engineering, Hanyang University					
	Understanding Domain Switching Kinetics in Ferroelectric HfO_2 : A					
	Pseudo-voigt and Machine Learning Approach					
TE1-D-5	Yong Hyeon Cho, Geun Hyeong Park, Dong Hyun Lee, Hyun Woo Jung, Young Min					
10:00-10:15	Kim, Ho Won Jang, and Min Hyuk Park					
	Department of Materials Science and Engineering, Inter-university Semiconductor					
	Research Center, Seoul National University					



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초청		, ,	Ŭ	of	Ferroelectric	Tunnel	Junctions	for	
TE1-D-6	Neuromorphic Computing								
10:15-10:45	Taehwan Moon								
	Department of Intelligence Semiconductor Engineering, Ajou University								